



IN THE CLAIMS

Please cancel Claims 2, 9, and 14-17.

Please amend the claims as follows:

*Crossed out*

1. (Amended) A method comprising:  
over an area of a substrate, forming a plurality of three dimensional first structures;

following forming the first structures, conformally introducing a sacrificial material over the area of the substrate;  
introducing a second structural material over the sacrificial material;  
exposing a portion of the sacrificial material; and  
removing the sacrificial material.

*Amend*

3. (Amended) The method of claim 1, wherein exposing a portion of the sacrificial material comprises removing a portion of the second structural material.

*Amend*

8. (Amended) A method comprising:  
over an area of a surface of a substrate, lithographically patterning a plurality of first structures, the plurality of first structures having a first dimension about the surface of the substrate and a second different dimension;

following forming the first structures, conformally introducing a sacrificial material layer over the area of the substrate;  
patterning the sacrificial material;  
forming second structures over the sacrificial material; and  
removing the sacrificial material.

*Amend*

11. (Amended) The method of claim 10, wherein exposing a portion of the sacrificial material comprises removing a portion of the second structural material.

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